

# Toxaphene

Column: **DB-35ms**

30m x 0.32 mm id, 0.25 µm film thickness

P/N: **123-3832**

Carrier: Helium at 45 cm/sec (EPC in constant flow mode)

Oven: 110°C for 0.5 min  
110-320°C at 15°C/min

320°C for 5 min

Injector: Splitless, 250°C  
30 sec purge activation time

1 µg/mL per component  
in Methanol

Detector: µECD, 350°C

Nitrogen makeup gas

(column + makeup flow = 30 mL/min constant flow)

**DB-35ms**

